

Title (en)

PROCESS FOR DEPOSITING AN ADHERENT METAL LAYER ON TITANIUM OR ITS ALLOYS

Publication

**EP 0341546 A3 19900516 (DE)**

Application

**EP 89107902 A 19890502**

Priority

DE 3816495 A 19880510

Abstract (en)

[origin: EP0341546A2] The invention relates to a process for depositing an adherent metal layer on titanium or its alloys by electroless deposition of a nickel-phosphorus alloy followed by heat treatment to form nickel-titanium diffusion layers, characterised in that the nickel layer then still present is coated with an adherent metal layer.

IPC 1-7

**C25D 5/38**; **C23C 18/36**

IPC 8 full level

**C23C 10/28** (2006.01); **C23C 18/36** (2006.01); **C23C 28/02** (2006.01); **C25D 5/38** (2006.01)

CPC (source: EP)

**C23C 18/36** (2013.01); **C25D 5/38** (2013.01)

Citation (search report)

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- [X] PATENT ABSTRACTS OF JAPAN, Band 11, Nr. 353 (C-457)[2800], 18. November 1987; & JP-A<sup>3</sup>62 124 290 (CITIZEN WATCH) 05-06-1987

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WO9953119A1

Designated contracting state (EPC)

BE CH DE ES FR GB IT LI LU NL SE

DOCDB simple family (publication)

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